Public reporting burden for this collection of information is estimated to average 1 hour per response, including the time for reviewing instructions, searching existing data sources, gathering and maintaining the data needed, and completing and reviewing this collection of information. Send comments regarding this burden estimate or any other aspect of this collection of information, including suggestions for reducing this burden to Department of Defense, Washington Headquarters Services, Directorate for Information Operations and Reports (0704-0188), 1215 Jefferson Davis Highway, Suite 1204, Arlington, VA 22202-4302. Respondents should be aware that notwithstanding any other provision of law, no person shall be subject to any penalty for failing to comply with a collection of information if it does not display a currently valid OMB control number. PLEASE DO NOT RETURN YOUR FORM TO THE ABOVE ADDRESS. 3. DATES COVERED (From - To) 2. REPORT TYPE 1. REPORT DATE (DD-MM-YYYY) View Graphs 03-03-2003 5a. CONTRACT NUMBER 4. TITLE AND SUBTITLE 5b. GRANT NUMBER POSS is Not Just a Sphere: Fluorinated POSS Materials (Living Next Door to a 5c. PROGRAM ELEMENT NUMBER Fluorine Chemist) **5d. PROJECT NUMBER** 6. AUTHOR(S) 4847 **5e. TASK NUMBER** Brent D. Viers, Joseph Mabry, Rene Gonzalez 0249 5f. WORK UNIT NUMBER 8. PERFORMING ORGANIZATION 7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES) REPORT NUMBER Air Force Research Laboratory (AFMC) AFRL-PR-ED-VG-2003-055 AFRL/PRSM 10 E. Saturn Blvd. Edwards AFB, CA 93524-7680 10. SPONSOR/MONITOR'S 9. SPONSORING / MONITORING AGENCY NAME(S) AND ADDRESS(ES) ACRONYM(S) Air Force Research Laboratory (AFMC) 11. SPONSOR/MONITOR'S AFRL/PRS NUMBER(S) 5 Pollux Drive AFRL-PR-ED-VG-2003-055 Edwards AFB CA 93524-7048 12. DISTRIBUTION / AVAILABILITY STATEMENT Approved for public release; distribution unlimited. 13. SUPPLEMENTARY NOTES 14. ABSTRACT 20031003 098 15. SUBJECT TERMS 19a. NAME OF RESPONSIBLE 18. NUMBER 17. LIMITATION 16. SECURITY CLASSIFICATION OF: **OF ABSTRACT** OF PAGES **PERSON**

c. THIS PAGE

Unclassified

Α

b. ABSTRACT

Unclassified

a. REPORT

Unclassified

REPORT DOCUMENTATION PAGE

19b. TELEPHONE NUMBER

Sheila Benner

(include area code)

(661) 275-5963

Form Approved

OMB No. 0704-0188

MEMORANDUM FOR PRS (In-House/Contractor Publication)

FROM: PROI (STINFO)



05 Mar 2003

SUBJECT: Authorization for Release of Technical Information, Control Number: AFRL-PR-ED-VG-2003-055
Brent D. Viers (AFRL/PRSM); Joseph Mabry (ERC); Capt. Rene I. Gonzalez (AFRL/PRSM), "POSS is Not Just a Sphere: Fluorinated POSS Materials (Living Next Door to a Fluorine Chemist)"

American Chemical Society Conference

(Statement A)

(New Orleans, LA, 23-27 Mar 2003) (Deadline: 24 Feb 2003 - PAST DUE)



DISTRIBUTION STATEMENT AApproved for Public Release
Distribution Unlimited















Living next door to a Fluorine Chemist

POSS is not just a sphere



Brent Viers, Joseph Mabry, Rene Gonzalez
AFRL/PRSM
Edwards AFB CA 93524
brent.viers@edwards.af.mil

DISTRIBUTION STATEMENT AApproved for Public Release
Distribution Unlimited



Anatomy of a Polyhedral Oligomeric Silsesquioxane (POSS) Molecule



Nonreactive organic (R) groups for solubilization and compatibilization.

and a R-R distance of 1.5 nm. Nanoscopic in size with an Si-Si distance of 0.5 nm

functional groups suitable for polymerization or grafting. - May possess one or more

(organic-inorganic) framework. Thermally and chemically robust hybrid

Precise three-dimensional structure for molecular level reinforcement of polymer segments and coils.

interaction at the nano-level (Edwards AFRL/PRSM ---> POSS monomers) The maximization of property enhancements in polymers results from





Physical properties of fluorinated Materials

Property	Pollyhedrai-	Polyethelyne
	2.2-2.3	0.92—1
Melting Temperature, °C	342 (first) 327 (second)	105-140
Dielectric Constant (1 kHz)	2.0	2.3
Dynamic Coefficient of Friction	₩0.0	0.33
Surface Energy, dynes/g	81	33
Resistance to Solvents and Chemicals	Excellent, No known solvent	Susceptible to hot hydrocarbons
Thermal Stability' T _{1/2} ,°C k ₃₅₀ %/min E _{rats} kJ/mol	505 0.000002 339	404 0.008 264
Melt Viscosity, ² Poise	1010-1013	104-6×104
Refractive Index	1.35	1.51
Chain Branching Propensity	No	Yes
		The state of the s

¹ T_{1,2} is the temperature at which 50% of the polymer is lost after thirty minutes heating in vacuum; k₁₅₀ is the rate of volatilization, i.e., weight less, at 350°C; B_{1d} is the activation energy of thermal degradation.

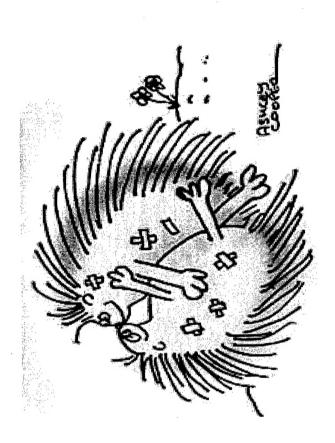
ergy of thempal degradation.

Melt creep viscosity for PTFE at 380°C, as specified in US Patent 3,819,594 (pub. 6/25/74).

- PTFE has one of the lowest surface energies among the organic polymers
- 2. PTFE is the most chemically resistant organic polymer
- PTFE is one of the most thermally stable among organic polymers
- PTFE's melting point and specific gravity are more than double PF's



How do Porcupines Mate

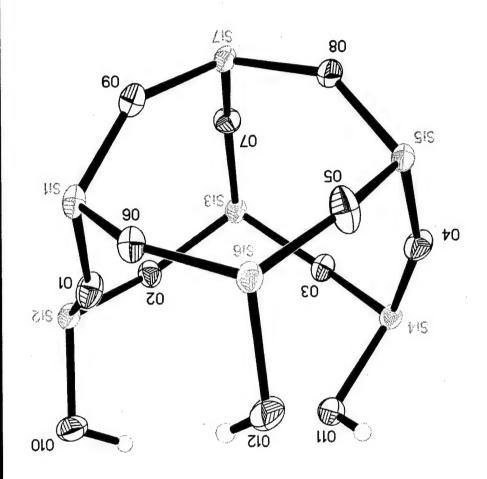


Very carefully!

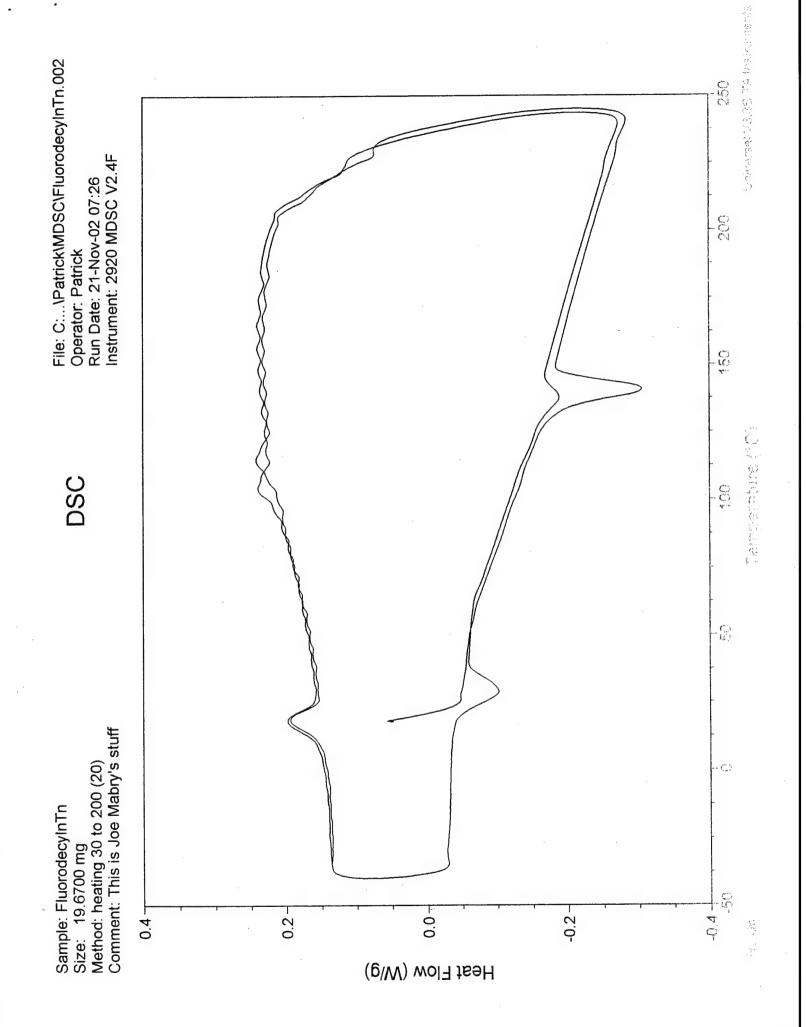




Crystal Structure of Perfluorinated POSS







0

Sample: RLB-IV-26 fluoroocty/878

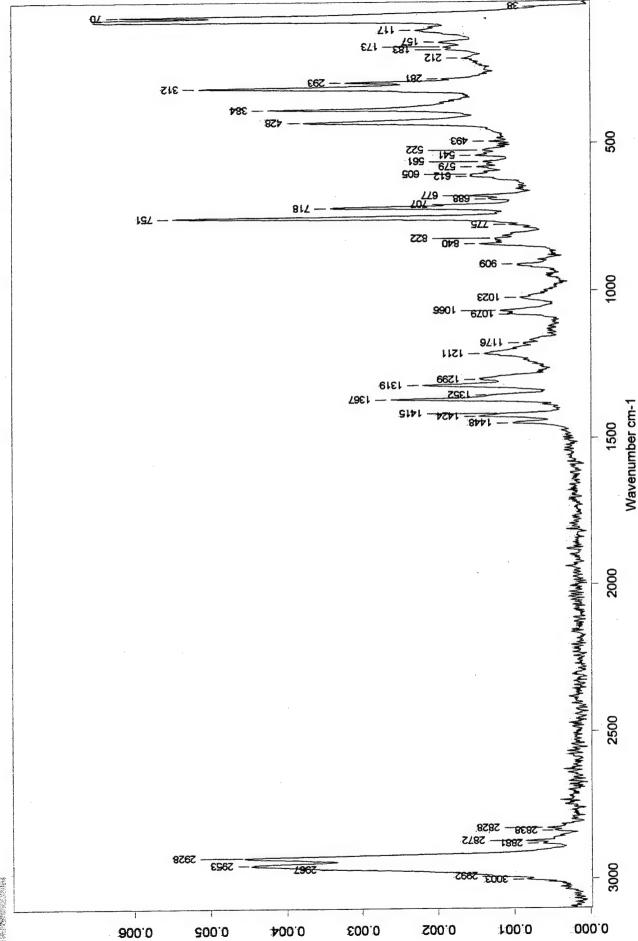
Sample Source: white powder Laser Power: 600

Sample Scans 500 Raman Laser Wavenumber 9394

HEDM/PRS EQUINOX 55

C:\opus_nt\WORK\Kerri\RLBIV26.1 2828 8582 1882 3000 3003 3885 kerri_new 100.0 000.0 200.0

Date Recorded: 24/02/2003 Time Recorded: 16:42:32



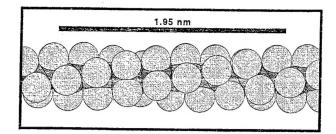


FIGURE 30.19. Polytetrafluorethylene (Form IV).

Polytetrafluoroethylene [-(CF₂)-] Form I (above 30 °C). Space group (hexagonal packing of helical chains of variable twist). Hexagonal approximation a=0.567 nm (35 °C) to 0.574 nm (218 °C). c=0.1300 nm per CF₂ group[†]. Cell volume=0.0362-0.0371 nm³ per CF₂ group. Density =2290-2240 kg/m³. Diffuse pattern with sharp hk0 reflections (hexagonal).

TABLE 30.11. Polytetrafluoroethylene [-(CF₂)-] Form II (below 19 °C). Observed hk0 reflections.^a

d-value (nm)	2θ (deg) (λ =0.1542 nm)	Relative intensity
0.4866	18.23	vvs
0.2823	31.69	vs
0.2447	36.73	s
0.2414	37.24	m
0.1850	49.26	m
0.1828	49.88	m
0.1627	56.58	m

^aSpace group (approximate) P1 $[C_1^1]$ (Complex structure with a regular helix of 2.1598 CF₂ units per turn). Orthogonal approximation; a=0.9649 nm; b=0.5648; and c=0.1300 nm per CF₂ group[†]. Cell volume=0.03542 nm³ per CF₂ group. Density=2340 kg/m³. (From Ref. 9.)

Polytetrafluoroethylene [-(CF₂)-] Form III (high pressure) Space group Pnam [D_{2h}^{16}]. a=0.75 nm; b=0.56 nm; and c=0.26 nm † . Cell volume=0.1092 nm 3 . Density=3040 kg/m 3 . Peaks attributed to a monoclinic phase are also observed. (From Ref. 10.)

TABLE 30.12. Polytetrafluoroethylene [-(CF_2)-] Form IV (19–30 °C).⁸

hkl	d value (nm)	2θ (deg) (λ=0.1542 nm)	Relative intensity
100	0.4902	18.10	VVS
110	0.2830	31.61	s
200	0.2451	36.67	s
210	0.1853	49.18	m
300	0.1634	56.30	m
220	0.1415	66.02	m
310	0.1359	69.09	m
107	0.2422	37.12	vs
108	0.2183	41.37	vs
117	0.1985	45.70	w
118	0.1847	49.34	W

^aSpace group (presumed) P3₁ or P3₂ [C_3^2 or C_3^3]; Rotational disorder of helical chains. $Z=15(\text{CF}_2)$. a=0.566 nm and c=1.95 nm[†]. Cell volume=0.0541 nm³. Density =2302 kg/m³. (From Refs. 8, 9, 11 and 12.)

30.8 POLY(P-PHENYLENE TEREPHTHALAMIDE) (PTTA) [—(C=O)—(C $_6$ H $_4$)—(C=O)—NH—($_6$ H $_4$) —(NH)—]

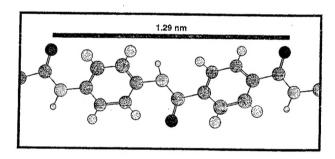


FIGURE 30.20. Poly(p-phenylene terephthalamide).

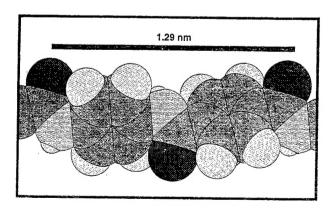


FIGURE 30.21. Poly (p-phenylene terephthalamide).

Linear Fluorocarbon Analogs



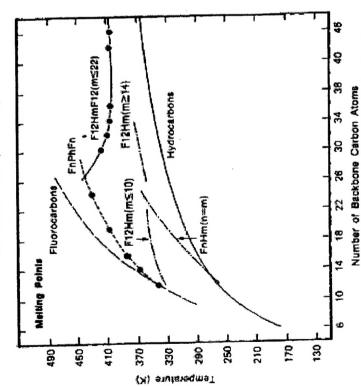


Figure 2. Comparison of the melting points of the FnPhFn triblocks with those of the n-alkanes, perfluoro-n-alkanes, and previously studied diblock and triblock materials.

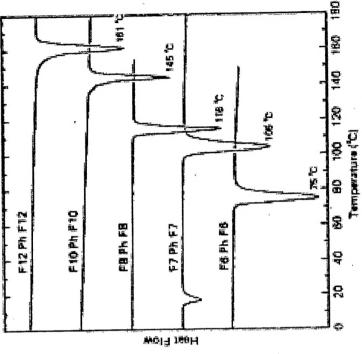


Figure 1. Differential scanning calorimetry thermograms of the PhPhPn triblocks. Temperatures refer to peak positions.



Tweig et. al.; Macromolecules 1991,24, 3901-3905



Conclusions

- Fluorosubstituted POSS has unusual melting behavior-evidence of polymorphs
- "coupled" arm motions although Raman spectroscopy does not show Melting point much higher than the arm melting-consistent with strong evidence of a lattice mode
- Frustrated Crystallization due to steric effects?
- Interactions with Karl Christe will solve the puzzle



Acknowledgments

- **AFOSR-Mike Berman**
- Bill Wilson, Ashwani Vij, Tini Vij
- POSS Group

